Application of Optical Emission Spectroscopy to Electron Cyclotron Resonance Ion Sources ICIS'23



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Abstract

International

Conference

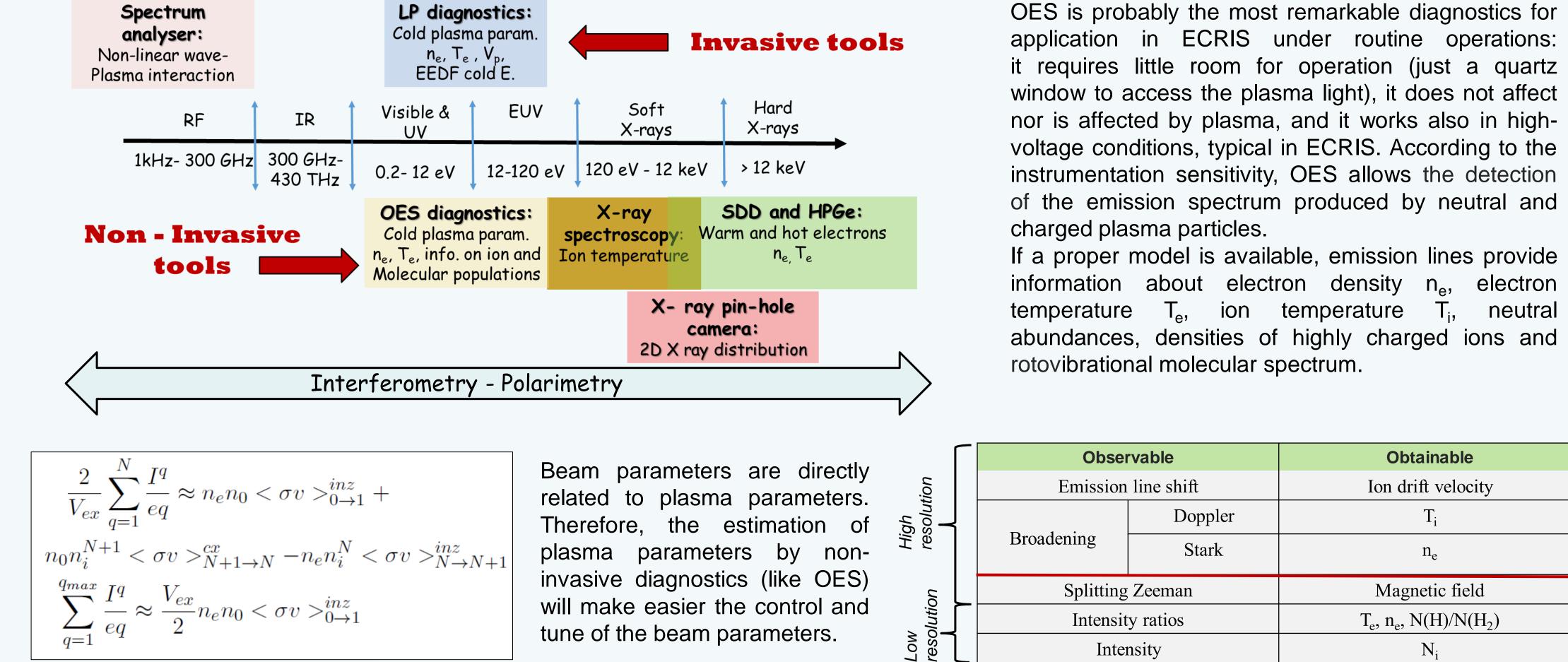
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on Ion Sources

Electron Cyclotron Resonance Ion Sources (ECRIS) are widely used to produce highly charged high intensity ion beams for research, medical and industrial applications.

ECRIS performances, namely the charge state distribution and beam intensity, depend critically on the electron energy distribution function.

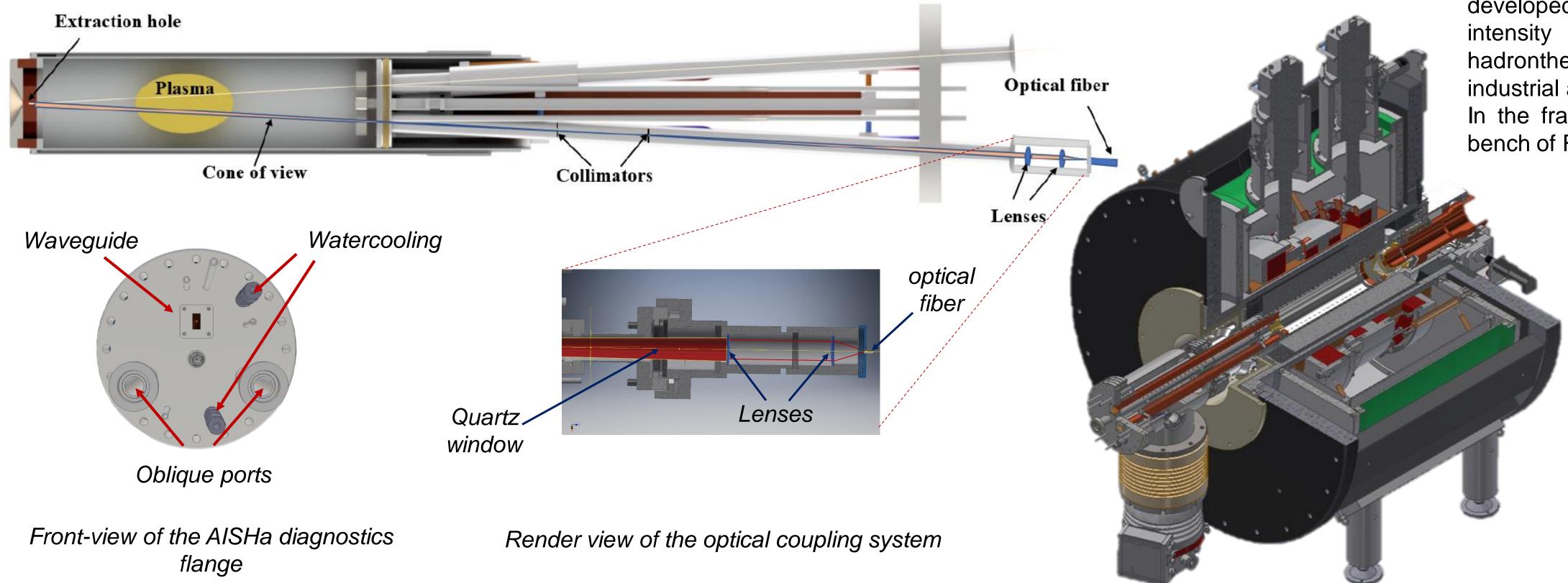
Further improvements of ECRIS performances can be achieved only by a deeper and deeper understanding of the plasma heating mechanisms and ion generation by means of opportune plasma diagnostics. Amongst others, Optical Emission Spectroscopy (OES) is the most remarkable for application in ECRIS: it is a noninvasive diagnostic able to operate also in high-voltage conditions and it requires only small room for operation. OES has been already tested for plasma diagnostics in proton sources. This work presents the experimental set-up developed for the plasma diagnostic of the Advanced Ion Source for Hadrontherapy (AISHa), an ECRIS for medical applications, together with the strategy used to relate plasma emission lines in the visible and near-infrared domain to plasma parameters for some ions of interest. Preliminary experimental results on a plasma reactor and perspectives will be also discussed.



Optical Emission Spectroscopy (OES) diagnostics

Experimental set-up on the AISHa test-bench

A proper diagnostics flange and optical coupling system have been designed to focus the light coming from a well-defined cone of view into an optical fiber connected to an iHR550 Horiba spectrometer. The lens focal length and the collimator dimensions have been chosen to create a cone of view focused on the extraction hole of the plasma chamber. This precaution avoids plasma light reflected by the chamber walls from being acquired by the spectrometer.



The Advanced Ion Source for Hadrontherapy (AISHA)

Intensity

The Advanced Ion Source for Hadrontherapy (AISHa) is an electron cyclotron resonance ion source operating at 18 GHz, developed at the INFN-LNS, with the aim of producing high intensity and low emittance highly charged ion beams for hadrontherapy purposes, but also to be a suitable choice for industrial and scientific applications.

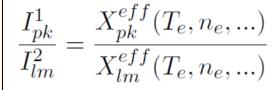
In the framework of the IONS project, AISHa will be the testbench of R&D activities on OES diagnostics in ECRIS plasmas.

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Radial field (max)	1.3
Axial field (max)	2.6/0.4/1.7
Operating frequency (GHz)/power (kW)	17.3-18.3/1.5
Cryostat length/diameter (mm)	620/5650
Extraction voltage (kV)	20-40
Plasma chamber ø (mm)	92 mm
Extraction hole ø (mm)	7.2
Distance between maxima of the axial field (mm)	370
Distance between microwave port and Bmin (mm)	203
Length of the resonance zone (mm)	<10
Distance between the plasma electrode and Bmin (mm)	167

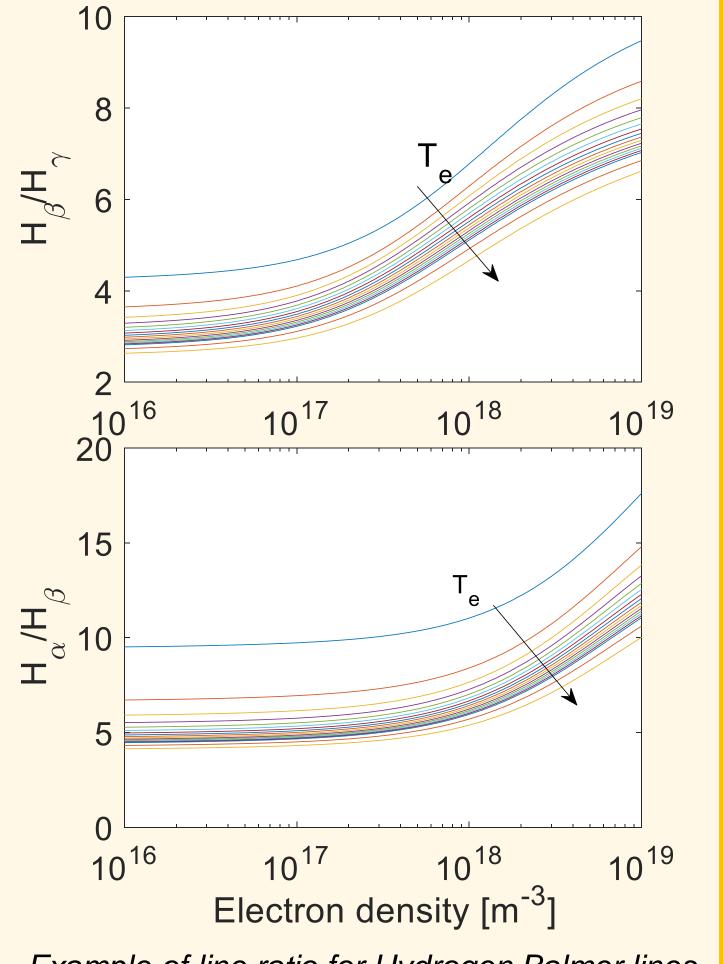
Theoretical approach

Collisional Radiative (CR) model

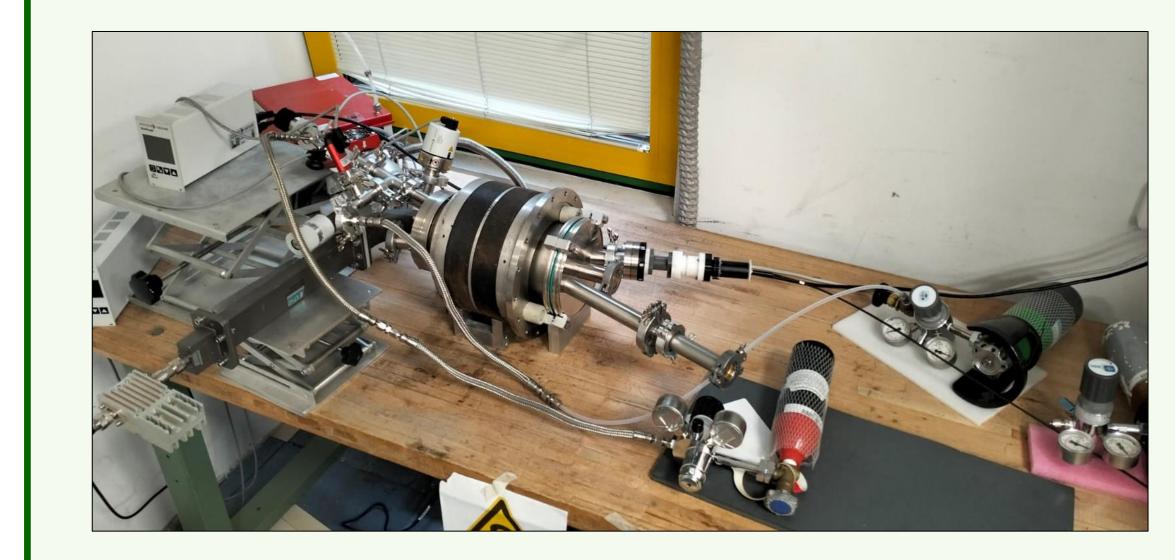


Line ratios are functions of plasma parameters.

The comparison between theoretical and experimental line ratio permits the evaluation of plasma parameters.



OES set-up commissioning on Plasma Reactor





Horiba iHR550

iHR550 is currently sensitive in the 300-			
750 nm wavelength domain with a spectral			
resolution of \sim 20 pm. Upgrade to the 150-			
1500 nm range is foreseen.			

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Range	150 to 1500 nm
Resolution	~0.02 nm
Aperture	f/6.4
Focal length	550 mm
Scan speed	160 nm/sec

Example of line ratio for Hydrogen Balmer lines evaluated by means of CR models.

The plasma Reactor is a flat-magnetic field plasma trap used for OES set-up commissioning. Hydrogen, helium and neon plasmas in overdense conditions have been generated by Electron Bernstein Wave heating. Typical working conditions are 3.8 GHz microwave frequency, 1.5-10⁻⁴ mbar neutral pressure and 0-150 W microwave power).



Picture of the optical coupling system

